

Amendments to the Claims:

This listing of claims will replace all prior versions, and listings, of claims in the application:

Listing of Claims:

1 (currently amended): An antistatic article comprising a support having deposited on the surface thereof at least one antistatic layer, wherein said antistatic layer comprises an electrically conductive material having interconnected areas of patterned coverage, ~~and~~ wherein said antistatic layer comprises a resistivity of between 10^{13} and 10^7 Ohms/sq., and wherein said patterned coverage comprises a gradient, wherein said gradient comprises areas of higher coverage and lower coverage.

2 (original): The article of Claim 1 wherein said conductive materials comprises at least one polyether polymeric conductive material.

3 (original): The article of Claim 2 wherein said polyether polymeric conductive material comprises polyether block copolyamide.

4 (original): The article of Claim 1 wherein said conductive material comprises a transparent conductive material.

5 (original): The article of Claim 4 wherein said transparent conductive material comprises a material transparent to visible light in the range from 400 to 700 nm.

6 (canceled):.

7 (canceled):

8 (original): The article of Claim 1 wherein said patterned coverage comprises areas of coverage and areas without coverage.

9 (original): The article of Claim 8 wherein said patterned coverage comprises a shape.

10 (original): The article of Claim 8 wherein said areas of coverage comprise a continuous conductive pathway.

11 (original): The article of Claim 10 wherein said areas of coverage comprise at least one line.

12 (original): The article of Claim 10 wherein said areas of coverage comprise at least one dot.

13 (original): The article of Claim 1 wherein said patterned coverage comprises a grid.

14 (canceled):

15 (currently amended): The article of Claim 1[[4]] wherein said areas of higher coverage comprise a resistivity of between 10^{13} and 10^7 Ohm/sq and said areas of lower coverage comprise a resistivity of greater than or equal to 10^{13} Ohm/sq.

16 (original): The article of Claim 1 wherein said antistatic layer comprises a layer applied by blade coating, wound wire rod coating, slot coating, slide hopper coating, gravure, or curtain coating.

17 (original): The article of Claim 1 wherein said antistatic layer comprises a layer applied by extrusion coating.

18 (original): The article of Claim 17 wherein said extrusion coating comprises simultaneous or consecutive extrusion.

19 (original): The article of Claim 1 wherein said antistatic layer comprises a printed layer.

20 (original): The article of Claim 1 wherein said support comprises an opaque support.

21 (original): The article of Claim 20 wherein said opaque support comprises paper.

22 (original): The article of Claim 1 wherein said support comprises oriented laminates.

23 (original): The article of Claim 1 wherein said support comprises a transparent support.

24 (original): The article of Claim 1 wherein said support comprises a core that has adhered thereto at least one flange layer.

25 (original): The article of Claim 24 wherein said core comprises paper.

26 (original): The article of Claim 24 wherein said core comprises a blown-cell foam core.

27 (original): The article of Claim 1 wherein said support comprises a microvoided support.

28 (previously presented): The article of Claim 29 wherein said conductive material comprises from 15 to 85% weight of said antistatic layer, and said polymer comprises from 15 to 85% by weight of said antistatic layer.

29 (original): The article of Claim 1 further comprising a carrier polymer.

30 (original): The article of Claim 29 wherein said polymer comprises polypropylene.

31 (original): The article of Claim 29 wherein said polymer comprises polyethylene.

32 (original): The article of Claim 29 wherein said polymer comprises polyurethane.

33 (original): The article of Claim 29 wherein said polymer comprises polymers and interpolymers selected from the group of polymers and interpolymers prepared from monomers selected from the group consisting of styrene, styrene derivatives, acrylic acid, acrylic acid derivatives, methacrylic acid, methacrylic acid derivatives, olefins, chlorinated olefins, acrylonitriles, methacrylonitriles, itaconic acid, itaconic acid derivatives, maleic acid, maleic acid derivatives, vinyl halides, vinylidene halides, vinyl monomer having a primary amine addition salt, and vinyl monomer containing an aminostyrene addition salt.

34 (original): The article of Claim 29 wherein said polymer comprises styrene and styrene derivatives, acrylics and acrylic acid derivatives, methacrylic acid and methacrylic acid derivatives.

35 (original): The article of Claim 29 wherein said polymer comprises polyester.

36 (original): The article of Claim 1 wherein said article comprises an imaging element having at least one imaging layer.

37 (original): The article of claim 36 wherein said imaging layer comprises a photosensitive silver halide imaging layer.

38 (original): The article of claim 36 wherein said imaging layer comprises an inkjet receiving layer.

39 (original): The article of claim 36 wherein said imaging layer comprises a thermal receiving layer.

40 (original): The article of claim 36 wherein said imaging layer comprises an electrophotographic imaging layer.

41 (original): The article of claim 36 wherein said imaging layer comprises an imaging assembly that comprises photohardenable microencapsulated coloring agents.

42 (original): The article of claim 36 wherein said imaging layer comprises plural heat-coloring elements, each comprising a diazo compound and a coupling component causing heat-coloring, and each of said diazo compounds in the heat-coloring elements being decomposed by radiation having a respectively different wavelength.

43 (previously presented): The article of Claim 36 wherein said antistatic layer comprises a layer on the same side of said support as said imaging layer.

44 (previously presented): The article of Claim 36 wherein said antistatic layer comprises a layer on the side of said support opposite said imaging layer.

45 (previously presented): The article of Claim 36 wherein said antistatic layer is on the side of said imaging layer opposite said support.

46 (previously presented): The article of Claim 36 wherein said antistatic layer is between said imaging layer and said support.

47 (previously presented): An antistatic article comprising a support having thereon at least one antistatic layer, wherein said antistatic layer comprises a conductive material having areas of patterned coverage, and wherein said support comprises a blown-cell foam core that has adhered thereto at least one flange layer.

48 (previously presented): An antistatic article comprising a support having thereon at least one antistatic layer, wherein said antistatic layer comprises a conductive material having areas of patterned coverage, and wherein said support comprises a microvoided support.

49 (previously presented) An antistatic article comprising a support having thereon at least one antistatic layer, wherein said antistatic layer comprises a conductive material having areas of patterned coverage, and at least one imaging layer comprising an imaging assembly that comprises photohardenable microencapsulated coloring agents.

50 (previously presented) An antistatic article comprising a support having thereon at least one antistatic layer, wherein said antistatic layer comprises a conductive material having areas of patterned coverage, and at least one imaging layer comprising plural heat-coloring elements, each comprising a diazo compound and a coupling component causing heat-coloring, and each of said diazo compounds in the heat-coloring elements being decomposed by radiation having a respectively different wavelength.

51 (new): An antistatic article comprising a support having deposited on the surface thereof at least one antistatic layer, wherein said antistatic layer comprises an electrically conductive material having interconnected areas of patterned coverage, wherein said antistatic layer, and wherein said article comprises an imaging element having at least one photosensitive silver halide imaging layer.

52 (new): The article of Claim 51 wherein said conductive material comprises a transparent conductive material.

53 (new): The article of Claim 51 wherein said patterned coverage comprises areas of coverage and areas without coverage.

54 (new): The article of Claim 53 wherein said patterned coverage comprises a shape.

55 (new): The article of Claim 53 wherein said areas of coverage comprise a continuous conductive pathway.

56 (new): The article of Claim 55 wherein said areas of coverage comprise at least one line.

57 (new): The article of Claim 55 wherein said areas of coverage comprise at least one dot.

58 (new): The article of Claim 51 wherein said patterned coverage comprises a grid.

59 (new): The article of Claim 51 wherein said patterned coverage comprises a gradient, wherein said gradient comprises areas of higher coverage and lower coverage.

60 (new): The article of Claim 59 wherein said areas of higher coverage comprise a resistivity of between 10^{13} and 10^7 Ohm/sq and said areas of lower coverage comprise a resistivity of greater than or equal to 10^{13} Ohm/sq.

61 (new): An antistatic article comprising a support having deposited on the surface thereof at least one antistatic layer, wherein said antistatic layer comprises an electrically conductive material having interconnected areas of patterned coverage, wherein said antistatic layer comprises a resistivity of between 10^{13} and 10^7 Ohms/sq., and wherein said article comprises an imaging element having at least one inkjet receiving layer.

62 (new): The article of Claim 61 wherein said conductive material comprises a transparent conductive material.

63 (new): The article of Claim 61 wherein said patterned coverage comprises areas of coverage and areas without coverage.

64 (new): The article of Claim 63 wherein said patterned coverage comprises a shape.

65 (new): The article of Claim 63 wherein said areas of coverage comprise a continuous conductive pathway.

66 (new): The article of Claim 65 wherein said areas of coverage comprise at least one line.

67 (new): The article of Claim 65 wherein said areas of coverage comprise at least one dot.

68 (new): The article of Claim 61 wherein said patterned coverage comprises a grid.

69 (new): The article of Claim 61 wherein said patterned coverage comprises a gradient, wherein said gradient comprises areas of higher coverage and lower coverage.

70 (new): The article of Claim 69 wherein said areas of higher coverage comprise a resistivity of between 10^{13} and 10^7 Ohm/sq and said areas of lower coverage comprise a resistivity of greater than or equal to 10^{13} Ohm/sq.

71 (new): An antistatic article comprising a support having deposited on the surface thereof at least one antistatic layer, wherein said antistatic layer comprises an electrically conductive material having interconnected areas of patterned coverage, and wherein said antistatic layer comprises a resistivity of between 10^{13} and 10^7 Ohms/sq.

72 (new): The article of Claim 71 wherein said conductive material comprises a transparent conductive material.

73 (new): The article of Claim 71 wherein said patterned coverage comprises areas of coverage and areas without coverage.

74 (new): The article of Claim 73 wherein said patterned coverage comprises a shape.

75 (new): The article of Claim 73 wherein said areas of coverage comprise a continuous conductive pathway.

76 (new): The article of Claim 75 wherein said areas of coverage comprise at least one line.

77 (new): The article of Claim 75 wherein said areas of coverage comprise at least one dot.

78 (new): The article of Claim 71 wherein said patterned coverage comprises a grid.

79 (new): The article of Claim 71 wherein said patterned coverage comprises a gradient, wherein said gradient comprises areas of higher coverage and lower coverage.

80 (new): The article of Claim 79 wherein said areas of higher coverage comprise a resistivity of between 10^{13} and 10^7 Ohm/sq and said areas of lower coverage comprise a resistivity of greater than or equal to 10^{13} Ohm/sq.

81 (new): The article of Claim 47 wherein said conductive material comprises a transparent conductive material.

82 (new): The article of Claim 81 wherein said transparent conductive material comprises a material transparent to visible light in the range from 400 to 700 nm.

83 (new): The article of Claim 47 wherein said patterned coverage comprises areas of coverage and areas without coverage.

84 (new): The article of Claim 83 wherein said patterned coverage comprises a shape.

85 (new): The article of Claim 83 wherein said areas of coverage comprise a continuous conductive pathway.

86 (new): The article of Claim 85 wherein said areas of coverage comprise at least one line.

87 (new): The article of Claim 85 wherein said areas of coverage comprise at least one dot.

88 (new): The article of Claim 47 wherein said patterned coverage comprises a grid.

89 (new): The article of Claim 47 wherein said patterned coverage comprises a gradient, wherein said gradient comprises areas of higher coverage and lower coverage.

90 (new): The article of Claim 89 wherein said areas of higher coverage comprise a resistivity of between 10^{13} and 10^7 Ohm/sq and said areas of lower coverage comprise a resistivity of greater than or equal to 10^{13} Ohm/sq.

91 (new): The article of Claim 49 wherein said conductive material comprises a transparent conductive material.

92 (new): The article of Claim 91 wherein said transparent conductive material comprises a material transparent to visible light in the range from 400 to 700 nm.

93 (new): The article of Claim 49 wherein said patterned coverage comprises areas of coverage and areas without coverage.

94 (new): The article of Claim 93 wherein said patterned coverage comprises a shape.

95 (new): The article of Claim 93 wherein said areas of coverage comprise a continuous conductive pathway.

96 (new): The article of Claim 95 wherein said areas of coverage comprise at least one line.

97 (new): The article of Claim 95 wherein said areas of coverage comprise at least one dot.

98 (new): The article of Claim 49 wherein said patterned coverage comprises a grid.

99 (new): The article of Claim 49 wherein said patterned coverage comprises a gradient, wherein said gradient comprises areas of higher coverage and lower coverage.

100 (new): The article of Claim 99 wherein said areas of higher coverage comprise a resistivity of between 10^{13} and 10^7 Ohm/sq and said areas of lower coverage comprise a resistivity of greater than or equal to 10^{13} Ohm/sq.

101 (new): The article of Claim 50 wherein said conductive material comprises a transparent conductive material.

102 (new): The article of Claim 101 wherein said transparent conductive material comprises a material transparent to visible light in the range from 400 to 700 nm.

103 (new): The article of Claim 50 wherein said patterned coverage comprises areas of coverage and areas without coverage.

104 (new): The article of Claim 103 wherein said patterned coverage comprises a shape.

105 (new): The article of Claim 103 wherein said areas of coverage comprise a continuous conductive pathway.

106 (new): The article of Claim 105 wherein said areas of coverage comprise at least one line.

107 (new): The article of Claim 105 wherein said areas of coverage comprise at least one dot.

108 (new): The article of Claim 50 wherein said patterned coverage comprises a grid.

109 (new): The article of Claim 50 wherein said patterned coverage comprises a gradient, wherein said gradient comprises areas of higher coverage and lower coverage.

110 (new): The article of Claim 109 wherein said areas of higher coverage comprise a resistivity of between 10^{13} and 10^7 Ohm/sq and said areas of lower coverage comprise a resistivity of greater than or equal to 10^{13} Ohm/sq.

111 (new): The article of Claim 48 wherein said conductive material comprises a transparent conductive material.

112 (new): The article of Claim 48 wherein said patterned coverage comprises areas of coverage and areas without coverage.

113 (new): The article of Claim 112 wherein said patterned coverage comprises a shape.

114 (new): The article of Claim 112 wherein said areas of coverage comprise a continuous conductive pathway.

115 (new): The article of Claim 114 wherein said areas of coverage comprise at least one line.

116 (new): The article of Claim 114 wherein said areas of coverage comprise at least one dot.

117 (new): The article of Claim 48 wherein said patterned coverage comprises a grid.

118 (new): The article of Claim 48 wherein said patterned coverage comprises a gradient, wherein said gradient comprises areas of higher coverage and lower coverage.

119 (new): The article of Claim 118 wherein said areas of higher coverage comprise a resistivity of between 10^{13} and 10^7 Ohm/sq and said areas of lower coverage comprise a resistivity of greater than or equal to 10^{13} Ohm/sq.